

Please fill out the attached MCLE attendance sheet, and send back to:

Melissa Woods

MCLE Coordinator

mwoods@orrick.com

2121 Main Street

Wheeling, WV 26003-2809



Attendance Sheet

ATTENDANCE VERIFICATION CODE: _____

If a code is spoken during the program to verify attendance, please write the code in the space above

Course: The 2011 Patent Reform Act: Implications for Your Company			Date: 10/11/2011
Location	Format	Time	Instructors
-	Webconference	10:00-11:00AM EDT	Chachkes, Alex V. Dyer, Barrington E.
New York (New York, NY)	Live Classroom	1:00-2:00PM EDT	Chachkes, Alex V. Dyer, Barrington E.
Silicon Valley (Menlo Park, CA)	Live Classroom	10:00-11:00AM PDT	Chachkes, Alex V. Dyer, Barrington E.
CA Credits: 1 General			
NY Credits: 1 PP - Transitional and Non-Transitional			

Name	Sign In	Time In	Sign Out	Time Out	License State	Bar Number	Email

Attendance monitored and verified by: _____

PLEASE RETURN TO MELISSA WOODS IN THE GOC (mwoods@orrick.com)



California MCLE Activity Evaluation Form - please return to mwoods@orrick.com

Course: The 2011 Patent Reform Act: Implications for Your Company

Date: 10/11/2011

Format: Live Classroom

Time: 10:00-11:00AM PDT

Instructor(s): Chachkes, Alex V.
Dyer, Barrington E.

Location: Silicon Valley (Menlo Park, CA)

CA CLE Credits: 1 General

NY CLE Credits: 1 PP - Transitional and Non-Transitional

1. Did this program meet your educational objectives?* (Rating)

Please rate on a scale of 1 to 5 (5 being the highest, best or most; 1 being the least, lowest or worst).

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

2. Did the environment have a positive influence on your learning experience?* (Rating)

Please rate on a scale of 1 to 5 (5 being the highest, best or most; 1 being the least, lowest or worst).

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

3. Were you provided with substantive written materials?* (Rating)

Please rate on a scale of 1 to 5 (5 being the highest, best or most; 1 being the least, lowest or worst).

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

4. Did the course update or keep you informed of your legal responsibilities?* (Rating)

Please rate on a scale of 1 to 5 (5 being the highest, best or most; 1 being the least, lowest or worst).

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

5. Did the activity contain significant current professional content?* (Rating)

Please rate on a scale of 1 to 5 (5 being the highest, best or most; 1 being the least, lowest or worst).

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

6. Please rate the faculty * (Rating, Instructor)

Overall teaching effectiveness

Instructor: Chachkes, Alex V.

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

Instructor: Dyer, Barrington E.

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1



California MCLE Activity Evaluation Form - please return to mwoods@orrick.com

Course: The 2011 Patent Reform Act: Implications for Your Company

Date: 10/11/2011

Time: 10:00-11:00AM PDT

Location: Silicon Valley (Menlo Park, CA)

7. Please rate the faculty * (Rating, Instructor)

Effectiveness of teaching methods

Instructor: Chachkes, Alex V.

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

Instructor: Dyer, Barrington E.

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

8. Please rate the faculty * (Rating, Instructor)

Significant current knowledge of subject

Instructor: Chachkes, Alex V.

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

Instructor: Dyer, Barrington E.

☐ 5 ☐ 4 ☐ 3 ☐ 2 ☐ 1

9. Name of Participant (optional): (Fill in the blank)

Additional Comments:

* Required Question



New York MCLE Activity Evaluation - please return to mwoods@orrick.com

Course: The 2011 Patent Reform Act: Implications for Your Company

Date: 10/11/2011

Format: Live Classroom

Time: 1:00-2:00PM EDT

Instructor(s): Chachkes, Alex V.
Dyer, Barrington E.

Location: New York (New York, NY)

CA CLE Credits: 1 General

NY CLE Credits: 1 PP - Transitional and Non-Transitional

1. Program Content (Multiple Choice)

Please rate:

☐ Excellent ☐ Good ☐ Fair ☐ Poor ☐ N/A

2. Instructor Quality (Multiple Choice, Instructor)

Please rate:

Instructor: Chachkes, Alex V.

☐ Excellent ☐ Good ☐ Fair ☐ Poor ☐ N/A

Instructor: Dyer, Barrington E.

☐ Excellent ☐ Good ☐ Fair ☐ Poor ☐ N/A

3. Written Materials (Multiple Choice)

Please rate:

☐ Excellent ☐ Good ☐ Fair ☐ Poor ☐ N/A

4. Facility (Multiple Choice)

Please rate:

☐ Excellent ☐ Good ☐ Fair ☐ Poor ☐ N/A

5. Effectiveness of Technology (Multiple Choice)

Please rate:

☐ Excellent ☐ Good ☐ Fair ☐ Poor ☐ N/A

6. Relevance (Multiple Choice)

Please rate:

☐ Excellent ☐ Good ☐ Fair ☐ Poor ☐ N/A



New York MCLE Activity Evaluation - please return to mwoods@orrick.com

Course: The 2011 Patent Reform Act: Implications for Your Company

Date: 10/11/2011

Time: 1:00-2:00PM EDT

Location: New York (New York, NY)

7. What was the most valuable part of this seminar? (*Essay*)

Comments:

8. What changes would you recommend to make the seminar more helpful to you? (*Essay*)

Comments:

9. General Comments (*Essay*)

Comments:

10. Name (optional) (*Fill in the blank*)

• _____